WEST Search History

DATE: Thursday, October 23, 2003

Set Name	Query	Hit Count	Set Name
side by side			result set
	DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L7	L6 and (ultrasonic$5 or megasonic$5 or transducer)	7	L7
L6	L4 and (((semiconductor or wafer or substrate) with (clean$3 or wash$3 or rins$3 or immers$3)) same (water or 'H.sub.2O') same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2'))	7	L6
L5	L4 and l2	0	L5
L4	yeol$.in.	495	L4
L3	L2 and l1	15	L3
L2	((semiconductor or wafer or substrate) with (clean$3 or wash$3 or rins$3 or immers$3)) same (water or 'H.sub.2O') same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2') same (ultrasonic$5 or megasonic$5 or transducer)	46	L2
L1	((134/1.3 |134/3 |134/18 |134/26 |134/28 |134/30 |134/902)!.CCLS. |(438/906)!.CCLS.)	7103	L1

END OF SEARCH HISTORY